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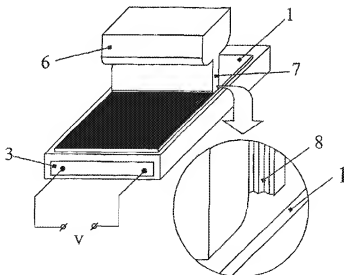
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(54) Title: METHOD OF OBTAINING ANISOTROPIC CRYSTALLINE FILMS AND DEVICES FOR IMPLEMENTATION OF THE METHOD



(57) Abstract: The invention pertains to the methods of obtaining anisotropic crystalline films and to devices for carrying out the methods. A colloidal system with anisometric particles is applied as a film onto the surface of a substrate (1) while the viscosity of the colloidal system is lowered. The particles of the colloidal system with lowered viscosity are oriented and the original viscosity of the colloidal system is restored. The film is then dried. The drying is carried out under controlled conditions. Zones of the dried film may be progressively heated to improve the film characteristics.

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## Method of Obtaining Anisotropic Crystalline Films and Devices for Implementation of the Method

### Related Applications

5 This application claims priority to Russian Application Nos. 2001103245 filed February 7, 2001, 2001106515 filed March 14, 2001, and 2001109980 filed April 16, 2001.

### Field of the Invention

10 This invention relates to a method and device for forming anisotropic films on a substrate, and more particularly to methods and devices for forming crystalline films from liquid crystal material for liquid crystal displays.

### Background Art

15 There are various known methods and devices for forming crystalline films from various materials. For example, to obtain films of polycrystalline silicon one uses known process of precipitation from a gas mixture of silane at low pressure. The process is labor-intensive and requires expensive equipment to form isotropic polycrystalline films.

20 There are also various known methods of epitaxial growth of monocrystalline films, which include gas epitaxy, molecular-beam epitaxy and liquid epitaxy. These processes are technologically labor-intensive and power consuming, requiring expensive equipment; moreover, there are a number of materials for which obtaining anisotropic crystalline films is an unsolved problem.

25 There are known methods of obtaining anisotropic films from liquid-crystalline (LC) solutions of organic dyes. The methods involve application of liquid-crystalline dye solution onto a substrate, application of external orienting action and drying, which provides films with optical anisotropy.

30 There is an increasing requirement to improve the parameters of various thin film devices and, accordingly, the characteristics and quality of films used in them. Thus, there is an increase in requirements to the degree of anisotropy and uniformity of characteristics in films functioning as polarizing coatings, orienting, phase-shifting, reflecting, brightening and other optical elements as well as anisotropic films for other purposes. It is necessary to create device elements based on anisotropic films with an increased degree of anisotropy, with a more perfect structure, and which do not contain admixtures or structural defects.

Summary of the invention

It is a general object of the present invention to provide: 1) an improved crystallization method which allows obtaining anisotropic crystalline films from colloidal systems (colloid solutions) of various matters, 2) a device for implementation of this method, and 3) thin  
5 crystalline films obtained with the method and/or device.

The technical result of the invention is the design of the new method of crystallization to create anisotropic crystalline films from colloidal systems of various matters, formed by the anisometric elements of the dispersion phase (kinetic units) distributed in liquid dispersion medium; simplicity and economy of the method, ensuring high degree of anisotropy and  
10 crystallinity of the obtained films, possibility to form crystalline films of arbitrary shape (including curvilinear), ecological cleanness of the process, low labor-intensity and power consumption. Devices for obtaining anisotropic crystalline films are characterized by the simplicity of implementation, ecological cleanness, they ensure obtaining films with high degree of anisotropy and good reproducibility of characteristics.

Description of Preferred Embodiments

The technical result of the first embodiment is achieved by the following steps: a) application of a layer of the colloidal system with anisometric particles (elements of the dispersion phase) onto the substrate, b) external action on the colloidal system to lower its  
20 viscosity, c) external orienting action on the system to provide dominating orientation of particles of the colloidal system, d) cessation of the external orienting action or application of additional external action to restore at least the initial viscosity value of the colloidal system, and e) drying under controlled conditions.

External action on the system to lower its viscosity and external orienting action on the  
25 system to provide dominating orientation of particles in the colloidal system can be applied simultaneously with lowering the viscosity or the external orienting action on the system can be applied after the process of lowering the viscosity. The external action on the system can be implemented via local and/or general heating of the substrate from the side opposite to that on which the film is formed, and/or local and/or general heating of the substrate and/or layer from  
30 the side of the forming film. Moreover, the heating can be implemented with electro-magnetic (IR, Microwave, etc.) radiation, and/or using resistive heater, and/or alternating electrical or magnetic field, and/or a flow of heated liquid and/or gas.

External action on the system can also be implemented via mechanical action on the layer of the colloidal system applied on the substrate, for example via shearing. Upon the surface of the

applied layer of colloidal system one directs at least one orienting tool, in the capacity of which one can use orienting knife-like and/or cylindrical rod, and/or flat plate positioned parallel to the applied layer, and/or at an angle to the surface of the applied layer, at the same time, the distance from the surface of the substrate to the edge or the plane of the orienting tool is set in order to obtain the desired film thickness. The surface of the orienting tool can have a relief. Additionally, the orienting tool can be heated.

Restoration to at least the original value of viscosity of the system is performed by cession of external action on the system immediately after completion of external orienting action or in the process of external orienting action.

Drying is preferably performed at humidity no less than 50% and room temperature.

#### Brief Description of the Drawings

The invention will be more clearly understood from the following description when read in conjunction with the accompanying drawings in which:

Figure 1 is a perspective view schematically illustrating one embodiment of a device for carrying out the present invention.

Figure 2 is a perspective view schematically illustrating another embodiment of a device for carrying out the present invention.

Figure 3 is a side elevational view schematically illustrating another device for carrying out the invention including controlled drying.

Figure 4 is a side elevational view of another embodiment of the device shown in Figure 3.

Figure 5 is a perspective view schematically illustrating a device for carrying out the invention including zone processing.

A device for carrying out the method of the first embodiment is schematically illustrated in Figure 1. The use of this device to fabricate a liquid crystal display is described using a 9.5 % aqueous solution of sulfonated indanthrone, which forms a hexagonal phase at room temperature. The dye, utilized in this example, when in solution, forms anisometric supramolecular complexes from molecules of the dye. These complexes will be the main foundation of the crystalline structure of the film. The original ink after purification is deposited onto the substrate 1 using dosimeter 2. We have also used such methods of deposition as pouring, smearing. They all yield approximately the same results in this method.

Further, the colloidal system is impacted so as to lower its viscosity, which is necessary to perform the subsequent crystal alignment. The solution forms nematic phase or a mixture of nematic and hexagonal phases. Viscosity of the system is lowered from about 1780 mPa/sec to about 250 mPa/sec. Quality anisotropic crystalline films have been obtained when we  
5 implemented this preliminary impact to lower viscosity of the system. Optimal implementation of the said external impact is by heating of the deposited layer from the bottom side of the substrate holder, which is carried out via thermal elements 3. The substrate holder is heated so as to raise the temperature of the deposited indanthrone layer to about 56°C. However, good results may also be obtained when heating the deposited layer with electromagnetic radiation or using  
10 other methods. A special case of implementation of the disclosed invention is the use of heated rod 4 to implement local lowering of viscosity of the system with simultaneous alignment of the crystalline material. The rod may be heated by an additional thermal element 5.

The next operation is the process of alignment of the kinetic units of the colloidal system (LLC). To implement the said external aligning impact, one may use various aligning tools. In  
15 this example we have used a cylindrical Mayer rod wound with a wire, which determined the thickness of the wet layer – 9.5 micrometers. When performing the aligning impact, the rate of translation of the rod was about 13 mm/sec. Shear stress generated by the rod resulted in additional lowering of viscosity of the system.

When alignment was completed, the heating of the substrate holder was stopped and the  
20 heated rod was removed. The film was then dried. Requirements for drying are such that the rate of removal of the solvent should be low in order to prevent disruptions of the previously aligned structure of the layer. In the above example, drying is performed at room temperature and humidity 60%. A device for providing controlled drying will be presently described.

By using this method we obtained anisotropic crystalline films with thickness of 0.3 – 0.4  
25 micron, with high degree of anisotropy of parameters: dichroic ratio -  $K_d=28$  with transmission  $T = 40\%$  (whereas with traditional method of fabrication  $K_d$  does not exceed 20), with good reproducibility of parameters, over the surface of the film, as well as from batch to batch. The crystalline structure of obtained films was evaluated by optical methods and methods of x-ray diffractometry.

30 A second embodiment of the invention is achieved by the following steps: a) external action on the colloidal system with anisometric particles, situated in a reservoir to lower its viscosity, b) external action on the system to provide dominant orientation of particles in the colloidal system via running it through a slot-die under pressure as the film is applied to the substrate, c) formation of film with heightened viscosity at the exit from the slot-die due to cession of the

external action or application of additional external action to provide restoration of at least the initial value of viscosity of the colloidal system, and d) drying.

External action on the system can be implemented via heating of the colloidal system situated in a reservoir. At the same time, the heating can be implemented with electromagnetic radiation, and/or resistive heater, and/or alternating electric or magnetic field, and/or a flow of heated fluid and/or gas. On the inner walls of a slot-die, external orienting action is implemented as the film is applied.

After application of layer of the colloidal system onto the substrate one can additionally implement orienting action on the system in the same direction as in the process of the main orienting action, created by the relief of the surface of the inner walls of the slot-die. In the process of forming crystalline film, the substrate can also be cooled to restore the original viscosity. Drying is preferably conducted at humidity levels of no less than 50% and room temperature.

The colloidal system can use LLC and use external action such as heating to obtain the phase transition in the system. The colloidal systems may contain crystalline anisotropic particles. Concentration of the dispersion phase in the colloidal system is chosen such as to provide thixotropy of the system. The kinetic units in the colloidal system can carry a charge.

After restoration of the initial value of viscosity of the colloidal system one can implement additional orienting action on the system in the same direction as in the process of the main orienting action.

A device for carrying out the method of the second embodiment using the same colloidal solution with the same concentration is schematically illustrated in Figure 2 where like reference numerals have been applied to like parts. The solution was placed in the reservoir 6 and heated to about 56°C, which resulted in the phase transition and lowering of viscosity from the original 1780 mPa/sec to 250 mPa/sec. Alignment was performed via extrusion from the slot 7 under the pressure of 1 atm higher. The gap between the walls of the slot was 50 mm; on one of the inner walls of the slot we formed a relief 8 with step size of 100 mm and height 10 mm. Alignment of LLC was performed in the slot itself during extrusion of the colloidal system through the slot. In the process of extrusion, the slot is translated over the substrate in such a way that the extruded layer was uniformly deposited onto the substrate. Viscosity in the deposited layer increased up to about 1500 mPa/sec due to the phase transition (since heating was only provided in the reservoir, temperature outside of the reservoir was room temperature). Drying operation was performed as described with respect to the first embodiment. The resulting anisotropic crystalline films had parameters analogous to those obtained in the first embodiment.

We have established that the conditions of drying determine perfection and peculiarities of the structure in the dried films. Drying conditions largely determine the degree of their crystallinity. As our experiments have shown, certain arrangements of the drying process enhance thermal stability of the films. A gradient, created over the substrate, promotes optimized advancement of the crystallization front, which will largely determine dimensions of the crystalline structure of the obtained films, and also will allow eliminating structural defects, which result from the orienting influence.

Technical result of the invention is the enhancement of perfection of the film's structure, enhancement of reproducibility of film's parameters over the surface of the film as well as through its thickness (elimination of defects from orienting influence), enhancement of anisotropy of properties and enhancement of thermal stability of the films.

Crystallization of the forming film takes place during the drying process, simultaneously with solvent removal. Therefore, by creating certain conditions for removing solvent fumes from the surface of the film one can regulate redistribution of solvent molecules inside the film, thus affecting crystallinity of its structure.

We have established that to perfect the film's structure, enhance degree of anisotropy and reproducibility of film's properties, it is necessary to provide conditions where removing the solvent happens slowly without (or with minimal) convection over the film's surface. Thus, arranged forced slowing of the drying rate, i.e. the quantity of solvent molecules leaving the film per unit of surface area per unit time, keeps solvent molecules in the film and slows the rate of their redistribution inside the films towards the surface. This slows the rate of crystallization and creates favorable conditions for aligning anisometric particles in the certain predetermined direction. Redistribution also takes place in the structure of the anisometric particles, which also favorably affects perfection of the crystalline structure of the forming film.

By the term finite volume in this case we mean the volume above the surface of the forming film, which is confined by a shell or a lid, where there are openings (slot, porous membrane, sliding panel of a shell and other), dimensions of which are such that the rate of deflecting the fumes is less than it would be if the process were performed in an infinite volume. By the term infinite volume we mean sufficiently large volume when an increase or a decrease of this volume over the surface of the forming film would not affect the rate of deflecting solvent fumes, i.e. the drying rate.

Therefore, the limiting stage of the drying process in the disclosed method is the rate and the direction of deflecting solvent fumes from the surface of the substrate. The process takes place according to diffusion kinetics, which creates more "calm" conditions for forming crystalline structure.



Since the process of removing the solvent is usually accompanied by significant change of geometric dimensions (thickness) and surface morphology of the film, by creating conditions to slow down the directional displacement of the solvent we thus create conditions for more gradual redistribution of solvent molecules in the film and more uniform and organized additional structuring of anisometric particles of the system (already after their external orientation) during drying process. This leads to lowering elastic stresses during crystallization process, which are due to geometrical deformation of the film. As a result, this enhances perfection of the film's structure and degree of its anisotropy.

By limiting the volume over the crystallizing film, we create conditions to increase solvent vapor pressure above the forming film, so that the effective solvent evaporation rate drops.

We use the term finite volume – when changing the volume affects the rate of removing molecules of an arbitrary material (in our case it is the solvent), i.e. the rate of drying. If the volume of a shell or a chamber, where the drying process takes place, will be sufficiently large, then changing it would not be noticeably reflected in the drying rate.

We have established experimentally that the mentioned technical result is achieved by the fact that in the process of forming crystalline anisotropic films from colloidal systems with anisometric particles, which includes application of the colloidal system onto the substrate and in situ and/or subsequent orienting influence and drying, the drying operation is performed at a temperature in the interval from 0° to 50°C and humidity in the interval from 60 to 90% with forced drying rate slowing via performing the drying process in a finite volume, which is selected with the condition to restrict deflection of solvent fumes from the surface of the forming film.

Moreover, the finite volume over the surface of the forming film may be created by performing the drying process in a shell covering at least a part of the surface of the wet film.

Figures 3 and 4 illustrate devices for drying in accordance with this embodiment of the invention. A liquid crystal solution 9 is fed from the reservoir 10 through the channel 11 onto substrate 12. The channel 11 has a traverse dimension so as to cover the entire width of film formation. The rate of feed of the solution from the reservoir 10 and the relative speed of translation of the reservoir and the feeding channel relative to the substrate 12 is determined by the desired thickness of the layer or film. Alignment of the supramolecular complexes in the layer of LC is preformed with Mayer rod 13 (metallic rod wound with a wire) by application of shear stress. The substrate with the deposited anisotropic film is then subjected to the drying operation (removal of the solvent from the layer of LC). Drying is performed in enclosure 14 in which the required conditions of temperature and humidity above the surface of the film are

established. Figure 3 shows the enclosure 14 covered by a semi-permeable membrane 15, which provides certain retardation of the drying process. In this example, with the pore diameter of about 15 nm and constant temperature of 18°C inside the enclosure, the humidity above the surface of the film was about 90%. To control conditions of the ambient medium during the process, the enclosure is equipped with humidity sensors 16 and temperature sensor 17. All the mentioned elements: enclosure 14, substrate 12, rod 13, and reservoir 10 and channel 11 have means for relative translation (not shown). All operations according to the disclosed invention may be combined in a single in-line process. In this case, all the elements mentioned above are mounted on a single frame 18. Operation of the system to form the film is as described with respect to Figures 1 and 2.

Another method of implementing forced slowing of the drying process is to make the enclosure with a lid 19 featuring a movable slit 20, Figure 4. Dimensions of the slit and its speed of translation should correspond to the condition of creating the required parameters of temperature and humidity above the surface of the film.

For different examples, we have obtained results, which show the influence of conditions of drying on the structure and properties of forming films. However in all examples, the index of degree of anisotropy of films, perfection of the structure of films, reproducibility of parameters of films over the area and throughout their thickness, as well as thermostability of films is significantly higher than analogous indexes obtained with regular drying conditions in air at room temperature (for comparison we used films obtained with identical conditions of deposition and alignment).

The following is an example of forming an anisotropic film from LLC of indanthrone. An eight percent weight aqueous LC solution of sulfonated indanthrone was deposited onto glass substrate via the known method (with external aligning influence on the colloidal system). In this solution, molecules are packed into stacks comprising supramolecular complexes, which are the anisometric particles of the system. When the LC solution is being aligned, these complexes are oriented along the direction of the aligning influence. Thickness of the film before drying was 5-10 µm. The sample was dried in various conditions: a) in air, in infinite volume at room temperature, b) in air, in infinite volume at temperature 10-15°C, c) in air, in a finite volume at temperature 20° C. The enclosure was 15mm away from the surface of the forming film with a porous membrane 15 with pore diameter 10-20 nm situated above the film for slowed removal of solvent vapors from the volume of the enclosure and to create humidity gradient along the normal to the surface of the film. In another experiment, in a finite volume at temperature 20°C created by the enclosure with lid 19 with its edge translating at the rate of 0.1 – 1 cm/min over

the surface of the forming film, and therefore creating tangential humidity gradient, wherein the direction of translation is such that propagation of the crystallization front is parallel to the direction of the aligning influence during formation. An analogous experiment was carried out with the direction of translation of the edge of the enclosure perpendicular to the direction of the aligning influence during formation.

Comparative analysis of the obtained films showed that implementing the disclosed method enhances optical characteristics of films by 15-30% compared to films obtained with "traditional" methods. Besides that, these methods "heal" the technological macro-defects: streaks and traces of the depositing and aligning tools (rod). As evident from x-ray investigations the films themselves also have more perfect crystalline structures. Increased thermal stability by about 10% is also characteristic of films that have been dried in the finite volume.

Additional results are obtained when using micro-porous membrane in the capacity of the substrate, additional translation of the thermal zone over the surface of the substrate, as well as implementation of automated operation of processes of formation of the film and control over the drying process itself and directly the process of formation of the film.

Usually, one uses porous membrane with pore diameter from 4 nm to 2 mm and porosity no less than 5%. Porosity is selected such as to provide a diffusion barrier to control the flow of gas (solvent). If it is necessary to perform accelerated drying while providing good results, one may use membrane with pore diameter on the order of 0.1 mm.

If one uses micro porous membrane for the substrate on which the colloidal system is deposited as a layer, removal of the solvent will take place through both surfaces of the forming film. Furthermore, parameters of the external membrane and the membrane of the substrate may be selected such that they will create the most identical conditions of removing the solvent, which would yield an even more perfect structure in the film. Usually, the size of pores in the internal and the external membranes are selected equal, or the pore size in the external membrane is chosen somewhat larger than in the internal one. Porosity of membranes is chosen different by depending on the necessary rate of solvent fumes removal. Optimally, porosity and membrane thickness are chosen such as to provide slowing of the drying process no less than by 1.5 times compared to the rate of drying in analogous conditions, but without slowing of the solvent fume deflection rate.

Drying of the forming film may be performed at a temperature less than the temperature of deposition and/or orientation of the colloidal system, or at a temperature equal to the temperature of deposition and/or orientation of the colloidal system, or at a temperature higher than the temperature of deposition and/or orientation of the colloidal system. Drying of the forming film

may be performed at humidity higher, equal or less than the one during deposition and/or orientation of the colloidal system.

In the disclosed method, the drying operation may also be performed in at least two stages, first of which is performed at temperature lower than the temperature of deposition and/or orientation of the colloidal system and humidity higher than the one during deposition and/or orientation of the colloidal system, but the last stage is performed at temperature and humidity which are equal to the ones that were used during deposition and/or orientation of the colloidal system.

Drying may be performed in air medium or in the medium of an inert gas, or in chemically active medium, which provides modification of properties of the forming film. To create the necessary medium, the substrate holder with the forming film on it together with the device restricting the rate of deflecting solvent fumes (shell with a slot or a membrane), are placed in an additional casing or reactor.

Usually, drying is carried on until the solvent content in the forming film is from 5% to 15 %. Additionally, after completing the drying process, the formed film may be aged at temperature from 60° to 150° and normal humidity. After that, a protective layer may be formed on it.

Drying may also be performed in the presence of temperature gradient provided by at least a single directed translation of the temperature zone over the surface of the forming film. Here, the direction of translation of the temperature zone is chosen at an angle from 0° to 180° to the direction of external orienting influence. Temperature zone may be moved over the film's surface two or more times. Then, direction of each subsequent translation is chosen to be at an angle from 0° to 90° to the previous one.

In the process of drying and/or after completion of the drying process, one may perform a single aging, of the forming or already formed film, at humidity level higher than that during the drying process. After that, one performs additional drying of the forming film. Such cyclic repetition of operations allows smoothing out stress effects on the crystal structure of the forming film introduced during fabrication.

We have found that additional thermal processing of the film obtained according to the invention leads to not only ablation of any unwanted admixtures, but also to enhanced characteristics of the film and enhanced degree of anisotropy. Additionally, we observed an increase in degree of crystallinity in the film, and enlargement of the supramolecular complexes themselves, which form the structure of the film. We have also found an increase in the thermal stability of the film. These results are achieved by thermal processing of the film or layer by a directional translation of a temperature zone along the substrate surface.

An example of a device for carrying out the zone heating is illustrated in Figure 5. As an example, let us consider obtaining anisotropic polarizing film from aqueous liquid crystal solution of sulfonated indanthrone. To obtain the liquid crystal we used 3.0 g. of sulfonated dye, free from inorganic salts, which is dissolved while heated in 37ml of solvent ( $H_2O$ ). Then, solution is cooled to room temperature. Presence of liquid crystal phase is registered when the sample is observed under polarizing microscope equipped with two crossed polarizers.

The liquid solution is fed under pressure from the reservoir 21 through the channel 22 onto the glass substrate 23. The LC solution is deposited onto the glass substrate with dimension  $100 \times 100 \text{ mm}^2$  at room temperature and humidity 70%, so as to obtain a film of LC with dimensions  $80 \times 80 \text{ mm}^2$ . The rod 24 in the form of rotating cylinder with diameter - 20 mm and length - 200 mm is placed above the flat surface of the substrate without possibility to move along it, but with possibility to rotate around its own axis. On the edges of the cylinder there are spacers 25, which are  $10 \mu\text{m}$  thick and 5mm wide. It is these pacers that determine the thickness of the film. Stage 26 with the substrate 23 is translated at 20 mm/sec relative to the stationary rotating cylinder so that the cylinder in effect is rolling on the surface of the substrate. In this process, liquid crystal of the dye is uniformly distributed over the surface of the substrate and the supramolecular complexes are aligned in the layer of LC. Until the moment of complete drying of the film, it is placed in the enclosure 27, which is built so that it hinders the evaporation of the solvent from the layer of LC, as described above.

A heating element 28, which creates a zone of elevated temperature in the layer of LC (about  $450^\circ\text{C}$ ), is translated above the surface of LC layer. The direction of translation of the thermal zone can be chosen to coincide with the direction of, or be perpendicular to, the external influence. Thermal influence is performed in conditions of elevated humidity (95%) in order to prevent complete drying of the film.

The speed of translation of the thermal zone is set to obtain uniform heating throughout the thickness of the film as it is formed. The speed of translation of the thermal zone is from 0.5 to 10 mm/sec. To create a sharper border of the thermal zone one may use additionally mountable screens.

As the result, we obtain anisotropic films, having the following characteristics:  $T_0 = 45\%$ ,  $D_{\perp}/D_{\parallel} = 22$  compared to  $D_{\perp}/D_{\parallel} = 16.5$  for films obtained with traditional methods without additional thermal processing.

To implement the disclosed invention one may use also other methods. For example: on the stage of the external aligning influence one may use a heated Mayer rod, or translate a heated wire under the substrate.

During implementation of the disclosed method, it is preferred to control all technological parameters of the process. Furthermore, manipulation of operations may be automated. One may use liquid crystal solution of an organic dye, where solution concentration determines the presence of anisometric particles – supramolecular complexes in solution. In an LLC, one may use at least one organic dye containing in its structural formula at least one ionogenic group providing its solubility in polar solvents in order to form lyotropic liquid crystal phase, and/or at least one anti-ion, both of which in the process of forming optically anisotropic film either remain in the structure of a molecule or not.

In order to obtain anisotropic films one may use various organic materials, which form colloidal system with anisometric particles. Molecules of the listed below materials have flat shape and when dissolved in a suitable solvent (usually just one) they form supramolecular complexes, which are the anisometric particles of the colloidal system. Based on LLC of the mentioned materials (which will be the very colloidal systems) one may obtain films with optical anisotropy. The following are examples of such organic materials:

- Dyestuffs (*Translator: in the original text Color Indices and some other additional information are absent; all these data are added to make the information more accurate*) :

- polymethine dyestuffs, for example, “pseudoisocyanine”, “pinacyanol”; triarylmethane dyes, for example “osnovnoi biriuzovii” (C.I. Basic Dye, 42035 (Turquoise Blue BB (By))), “kislottii yarko-goluboi 3” (C.I. Acid Blue 1, 4204);

- diaminoxanthene dyes, for example, “sulforhodamine S” (C.I. Acid Red 52, 45100 (Sulforhodamine B));

- acridine dyes, for example, “osnovnoi zhoitii K” (C.I. Basic Dye, 46025 (Acridine Yellow G and T(L)));

- sulfonation products of acridine dyes, for example, of “trans-quinacridone” (C.I.

Pigment Violet 19, 46500 (trans-Quinacridone));

- water-soluble derivatives of anthraquinone dyes, for example, “aktivnii yarko-goluboi KH” (C.I. Reactive Blue 4, 61205);

- sulfonation products of vat dyes, for example, of “flavantrone” (C.I. Vat Yellow 1, 70600 (Flavanthrone)), of “indantrenovii zhoitii” (C.I. Vat Yellow 28, 69000), of “kubovii zhoitii 4K” (C.I. Vat Orange 11, 70805), of “kubovii tyomno-zelenii Zh” (C.I. Vat Green 3, 69500), of “kubovii fioletovii S” (C.I. Vat Violet 13, 68700), of indanthrone (C.I. Vat Blue 4, 69800 (Indanthrone)), of perylene violet dye (CAS: 55034-81-6), of “kubovii alyi 2Z” (C.I. Vat Red 14, 71110);

- azo-dyes, for example, Benzopurpurine 4B (C.I. Direct Red 2, 23500), “Pryamoy zheltii svetoprochniy O”, “Pryamoy zheltii svetoprochniy” (C.I. Direct Yellow 28, 19555);

- water soluble diazine dyes, for example, "Kislotnii temno-goluboi Z" (C.I. Acid Blue 102, 50320);
- sulfonation products of dioxazine dyes, for example, of "pigment fioletovii dioxazinovii" (C.I. Pigment Violet 23, 51319);
- water-soluble thiazine dyes, for example, C.I. Basic Blue 9, 52015 (Methylene Blue);
- water-soluble derivatives of phthalocyanine dyes, for example, cupric octacarboxyphthalocyanine salts;
- fluorescent bleaches,

as well as other organic materials, for example, disodium-chromeglycate etc., and inorganic materials capable of forming colloidal system with anisometric particles.

In the capacity of the colloidal system one may also use systems created from inorganic lyotropic liquid crystals, such as iron oxohydroxide or vanadium oxide and others.

There has been described a method of obtaining thin anisotropic crystalline films includes application of colloidal system with anisometric particles, or macromolecules, or supra-molecular complexes, which are formed by the grouped and oriented in some way molecules existing in pre-crystalline state onto the substrate. It is preferred that the degree of anisotropy (the ratio of the length to the thickness) of kinetic units of the colloidal system are no less than 10. Colloidal system should also exhibit thixotropy. For this purpose, colloidal system should exist at a certain temperature and have certain concentration of the dispersion phase. The colloidal system (or paste) is brought into the state of heightened fluidity via any type of external action, which lowers viscosity of the system. This could be heating, deformation, etc. External action can continue during the entire next process of orientation or take the time necessary in order that the system does not relax into the state with heightened viscosity during the orientation time.

The next operation of the method is the external orienting action on the system, which could be implemented as by mechanical as well as any other method. The degree of mentioned action should be sufficient so that kinetic units of the colloidal system obtain the desired orientation and form the structure, which will be the foundation of the future crystal lattice in the obtained film. Operations of rendering the colloidal system into fluid state and external orienting action on it can be joined in time and performed sequentially on various regions of the film.

The next operation of the declared method is rendering of the oriented area of the obtained film from the state with lowered viscosity, which was achieved by the first external action, into the state with the initial or higher viscosity. This is implemented so as to avoid disorientation of the structure and creating defects on the surface of the film. This operation is necessary and

cannot be implemented as just a process of free or forced drying, i.e. removing the solvent from the formed film. Before the drying process, viscosity of the system should be raised either by removing the earlier applied action, which provided lowering of the viscosity before the orienting process, or by an additional forced action on the system to "freeze" its structure. Only  
5 thixotropic colloidal systems, when exerted with the above actions can ensure obtaining the desired results at each of the above-listed intermediate stages of forming anisotropic crystalline films.

The final operation of the declared method is the drying operation (solvent removal), in the process of which the crystalline structure in the obtained film is formed. Regimes of drying  
10 operation should be chosen so as to eliminate the possibility of disorientation of the earlier obtained structure and provide relaxation of stresses ("smoothing" of the crystalline lattice defects) appearing during external orienting action. It is preferred to perform drying process at raised humidity (no less than 50% at room temperature). The critical factor for obtaining high degree of crystallinity in the obtained film will be the speed and directionality of the solvent  
15 removal out of the system.



What is claimed is:

1. A method of fabricating anisotropic crystalline films comprising the steps of:  
applying a layer of a colloidal system with anisometric particles onto a substrate,  
externally impacting the colloidal system to lower the viscosity of the applied layer of the  
5 colloidal system,  
applying external orienting action on the colloidal system to provide dominant orientation  
of particles of the colloidal system,  
allowing the deposited colloidal system with dominant orientation of the particles to  
return to at least its initial value of viscosity, and  
10 drying the deposited layer.

2. The method of claim 1 wherein the external impact on the colloidal system to  
lower its viscosity and external orienting action on the system to introduce the dominant  
orientation of particles of the colloidal system are carried out simultaneously.

3. The method of claim 1 wherein external impact on the colloidal system comprises  
heating the colloidal system to lower its viscosity prior to applying the orienting action.

4. The method of claim 3 wherein the heating is performed by radiation, and/or resistive  
20 heater, and/or alternating electrical or magnetic field, and/or a flow of heated liquid and/or gas.

5. The method of claim 1 or 2 wherein external impact on the system is performed via  
mechanical action on the layer of colloidal system as it is applied onto the substrate.

6. The method of claim 1, 2 or 3 wherein external orienting action on the colloidal system  
layer is performed via mechanical directed translation over the layer of at least one orienting tool with the  
distance from the surface of the substrate to the edge or the plane of the orienting tool is set to obtain  
desired film thickness.

7. The method of claim 6 wherein the orienting tool is heated.

8. The method of claim 1 wherein the step of allowing viscosity of the system to return to its initial value is achieved right after completion of the external orienting action.

9. The method of claim 1, 2 or 3 wherein drying is performed at room temperature at a  
5 humidity level no less than 50%.

10. The method of claim 1 wherein the anisometric particles in the colloidal system are crystalline.

11. The method of claim 1 wherein lyotropic liquid crystal is used in the capacity of the colloidal system.

12. The method of claim 1 wherein external impact is chosen such as to ensure phase transition in the system.

15

13. The method of claim 1 wherein sol or gel are used in the capacity of the colloidal system.

14. The method of claim 1 wherein concentration of dispersion phase of a colloidal system is chosen such as to provide thixotropy of the system.

20

15. The method of claim 1 wherein kinetic units in the colloidal system carry a charge.

16. The method of fabricating anisotropic crystalline films comprising the steps of:

externally impacting the colloidal system with anisometric particles situated in a reservoir to lower  
25 the viscosity,

external orienting action on the colloidal system to provide the dominant orientation of particles of the colloid system via running it through the slot-die under pressure,

formation of film with raised viscosity upon exiting from the slot-die due to cession of the external impact or application of an additional external impact to provide restoration of at least the initial value of  
30 viscosity of the colloid system,

application of the film onto the substrate and

drying the deposited layer.

17. The method according to claim 16 wherein external orienting action to provide dominant orientation of particles of the colloid system is performed in the process of the external impact on the system to lower its viscosity.

18. The method according to claims 16 wherein external orienting action on the system is performed  
5 via heating the colloid system, placed in the reservoir.

19. The method according to claim 18 wherein the heating is performed by radiation, and/or resistive heater, and/or alternating electrical or magnetic field, and/or a flow of heated liquid or gas.

20. The method according to claim 16 wherein external orienting action is performed using the slot-die, inner walls of which feature the orienting relief.

10 21. The method according to claim 16 wherein the substrate is additionally cooled.

22. The method according to claim 16 wherein drying is performed at humidity level no less than 50% and room temperature.

23. The method according to claim 16 wherein lyotropic liquid crystal is used in the capacity of the colloid system.

15 24. The method according to claim 23 wherein external action is chosen such as to ensure phase transition in the colloid system

25. The method according to claim 16 wherein sol or gel are used in the capacity of the colloid system.

20 26. The method according to claim 16 wherein the anisometric particles in the colloid system are crystalline.

27. The method according to claim 16 wherein one uses colloid system, concentration of dispersion phase in which is chosen such as to provide thixotropy of the system.

28. The method according to claims 16 wherein kinetic particles in the system carry charge.

29. An anisotropic crystalline film formed by the method of claim 1 or 16.

25

30. A device for fabricating a crystalline film on a substrate comprising:

a substrate holder,

means mounted a selected distance above the substrate for applying a layer of a colloidal system with anisotropic particles of predetermined thickness onto a substrate carried by the

30 substrate holder,

an orienting tool for applying an orienting action on the colloidal system applied to the substrate, and

means for heating the colloidal system applied to the substrate.

31. A device as in claim 30 wherein the means for heating the colloidal system heats at least part of the substrate holder.

32. A device as in claim 30 wherein said means mounted a selected distance above the substrate holder for applying a layer of colloidal system comprises a reservoir for storing the colloidal system which includes a slot die for delivering the colloidal system onto the substrate.

33. A device for fabricating a crystalline film on a substrate comprising:

a reservoir for placing the colloid system, supplied with heating elements and means of creating extra pressure in the reservoir,

a substrate holder, installed at a controlled distance under the reservoir with possibility of movement relative to the reservoir in the horizontal plane;

and where the lower part of the reservoir has an opening in the shape of a slot-die, dictating conditions of the orienting impact.

34. Device according to claim 33 wherein under the substrate holder there is a thermo-element implemented such that it allows maintaining certain temperature over at least a part of the substrate holder surface.

35. Device according to claim 33 wherein it is additionally supplied with a means of directing 3and control over the process of film formation.

36. Device according to claim 33 wherein at least a part of the slot-die surface features a relief and/or hydrophilic or hydrophobic coating.

37. A method of fabricating anisotropic crystalline films from colloidal systems with anisometric particles comprising the steps of:

deposition of a layer of the colloidal system onto a substrate,

the simultaneous and/or subsequent applying of orienting action to the layer to provide dominant orientation of the particles, and

drying the layer at a temperature in the interval 0° to 50°C and humidity in the interval from 60 to 90% with forced slowing of the drying rate by performing the process in a finite volume, which is configured to resist deflection of solvent fumes from the surface of the forming film.

38. The method of claim 37 wherein the finite volume over the surface of the forming film is created by performing the drying operation in a shell encasing at least a part of the surface of the layer.

39. The method of claim 38 wherein the maximum distance from the inner surface of the shell to the surface of the layer does not exceed 20 mm.

40. The method of claim 37,38 or 39 wherein during the process of drying of the forming film, humidity gradients are created in tangential and/or normal direction above the film surface.

41. The method of claim 40 wherein tangential humidity gradient above the surface of the forming film is created via at least a single shifting of the shell along the film surface in at least one direction.

42. The method of claim 40 wherein the shell includes a slot and the slot is translated in at least one direction.

43. The method of claim 40 wherein the normal and/or tangential humidity gradient is implemented in the form of porous membrane forming a part of the shell.

44. The method of claim 37 or 38 wherein the drying operation is performed in at least two stages, the first of which is performed at a temperature lower than the temperature of deposition and/or orientation of the colloidal system, and humidity higher than the humidity of deposition and/or orientation of the colloidal system, while the last stage is performed at temperature and humidity equal to those used during deposition and/or orientation of the colloidal system.

45. The method of claim 40 or 41 wherein during the drying process the speed of movement of the shell over the film surface and/or the speed of movement of the slot are selected such as to lower the humidity of the forming film by at least 20% during a single pass of the shell edge or the slot above the film surface.

46. The method of claim 43 wherein the drying process utilizes porous membrane with pore diameter from 4 nm to 2 μm and porosity no less than 5%.

47. The method of claim 43 wherein a microporous membrane is used as the substrate for deposition of the colloidal system.

48. The method of claim 37 wherein drying is performed until solvent content in the film is 2-15%.

49. The method of claim 37 wherein drying is performed under temperature gradient provided by a single directional translation of temperature zone over the forming film surface.

50. The method of claim 37 wherein direction of translation of the temperature zone is selected at an angle from 0° to 180° to the direction of the orienting action.

51. The method of claim 37 wherein, in the case of multiple translation of the temperature over the film surface, the direction of each subsequent translation is chosen at an angle from 0° to 90° to the direction of the previous translation.

52. The method of claim 37 wherein, after completion of the drying process, the formed film is aged at temperature from 60° to 150° and normal humidity.

53. A method of fabricating anisotropic crystalline films comprising the steps of:  
applying a layer of a colloidal system with anisometric particles onto a substrate,  
externally impacting the colloidal system to lower the viscosity of the applied layer of the colloidal system.  
applying external orienting action on the colloidal system to provide dominant orientation of particles of the colloidal system,  
allowing the deposited colloidal system with dominant orientation of the particles to return to at least its initial value of viscosity, and  
drying the deposited layer at a temperature in the interval 0° to 50°C and humidity in the interval from 60 to 90% with forced slowing of the drying rate by performing the process in a finite volume which is configured to resist deflection of solvent fumes from the surface of the forming film.

54. A method of fabricating anisotropic crystalline films from colloidal systems with anisotropic particles comprising the steps of:  
applying a layer of the colloidal system onto a substrate,  
applying external orienting action on the layer to provide primary orientation of particles of the colloidal system,  
drying of the obtained layer, and  
thermally processing the layer on the substrate surface via at least a single directional pass of the temperature zone along the layer.

55. The method of claim 54 wherein the colloidal system comprises lyotropic liquid crystal.

56. The method of claim 54 wherein the colloidal system comprises a sol or a gel.

57. The method of claim 55 or 56 wherein kinetic particles in the colloidal system carry a charge.

58. The method of claim 54 wherein temperature zone is created via local heating of the substrate on the side opposite to that on which the film is formed.

59. The method of claim 54 wherein the temperature zone is created via local heating of the surface of the film.

60. The method of claim 54 wherein simultaneously with the local heating in the temperature zone, the rest of the substrate and/or layer of colloidal system is locally or globally cooled.

61. The method of claim 54 wherein the temperature of the heating zone is chosen to be no less than 10° higher than the substrate temperature and no less than 10° less than the decomposition temperature of the film material.

62. The method of claim 54 wherein heating is implemented no higher than 180°C.

63. The method of claim 54 wherein the direction of translation of the temperature zone is chosen to coincide with the direction of the orientation.

64. The method of claim 54, 61, 62 or 63 wherein multiple passes of the temperature zone are performed with the direction of each subsequent pass chosen at an angle from 0 to 180° to the previous one.

65. The method of claim 54, 61, 62 or 63 wherein the speed of movement of the temperature zone is chosen out of the condition to establish uniform heating of the layer in the specified zone throughout the entire thickness and simultaneously maintain temperature gradient in the layer along the substrate surface.

66. The method of claim 60 wherein the width of the translating temperature zone is chosen equal to the width of the forming film.

67. The method of claim 54 wherein application of a colloidal system onto the substrate and/or external orienting influence on the system, and/or drying of the obtained layer, and/or thermal processing of the layer is carried out at humidity no less than 40%.

68. The method of claim 54 wherein during application of colloidal system onto the substrate, and/or external orienting action on the system, and/or drying of the obtained layer, and/or thermal processing of the layer one creates humidity gradient along the substrate surface.

69. The method of claim 54 wherein for at least a part of the time during formation of the anisotropic film the applied layer is under constant electric and/or magnetic field.

70. The method of claim 54 wherein the temperature zone is created by heating means which orient the anisotropic particles.

71. A method of fabricating anisotropic crystalline films comprising the steps of:  
applying a layer of a colloidal system with anisometric particles onto a substrate,  
externally impacting the colloidal system to lower the viscosity of the applied layer of the colloidal system,  
applying external orienting action on the colloidal system to provide dominant orientation of particles of the colloidal system,  
allowing the deposited colloidal system with dominant orientation of the particles to return to at least its initial value of viscosity,  
drying the deposited layer at a temperature in the interval 0° to 50°C and humidity in the interval from 60 to 90% with forced slowing of the drying rate by performing the process in a finite volume which is configured to resist deflection of solvent fumes from the surface of the forming film, and  
thermally processing the layer on the substrate surface by at least a single directional pass of a temperature zone along the layer.

72. A method of obtaining anisotropic crystalline films comprising the steps of:  
applying a layer of a colloidal system with anisometric particles onto a substrate,



externally impacting the colloidal system to lower the viscosity of the applied layer of the colloidal system,

applying external orienting action on the colloidal system to provide dominant orientation of particles of the colloidal system,

5 allowing the deposited colloidal system with dominant orientation of the particles to return to at least its initial value of viscosity,

drying the deposited layer, and

thermally processing the layer on the substrate surface by at least a single directional pass of a temperature zone along the layer.

10

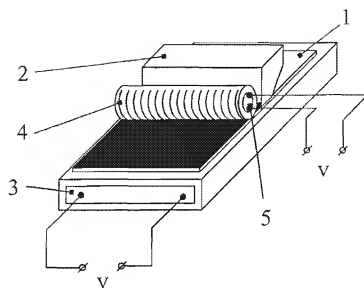


Fig. 1

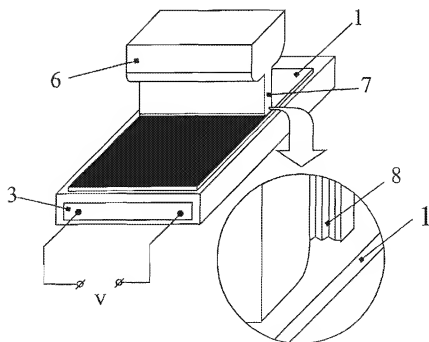


Fig. 2

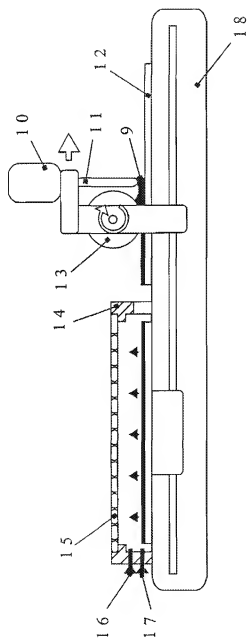


Fig. 3

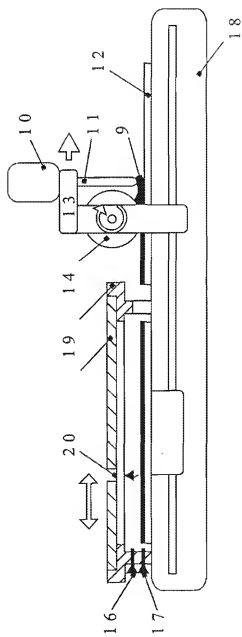


Fig. 4

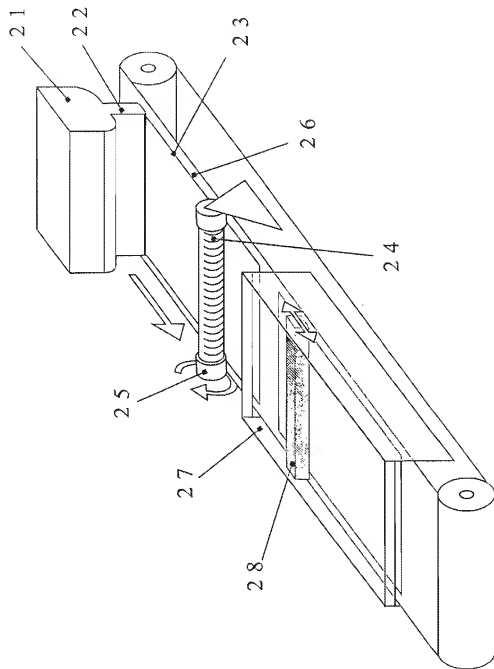


Fig. 5

## INTERNATIONAL SEARCH REPORT

International application No.

PCT/US02/03800

<b>A. CLASSIFICATION OF SUBJECT MATTER</b>		
IPC(7)	H01L 21/00	
US CL	438/30,780; 118/410,500	
According to International Patent Classification (IPC) or to both national classification and IPC		
<b>B. FIELDS SEARCHED</b>		
Minimum documentation searched (classification system followed by classification symbols) U.S.: 438/30,780; 118/410,500,428; 430/20; 216/23		
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched		
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)		
<b>C. DOCUMENTS CONSIDERED TO BE RELEVANT</b>		
Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 4,143,187 A (PILGRIM et al) 06 March 1979 (06.03.1979) See figure 2.	30-36
Y	US 2,320,702 A (J.MARCHESE et al) 01 June 1943 (01.06.1943), see figure 3.	30-36
A	US 5,073,219 A (MCARDLE et al) 17 December 1991 (17.12.1991), see whole document.	1-72
A	US 4,702,558 A (COLES et al) 27 October 1987 (27.10.1987), see Abstract.	1-29, 37-72
A	US 4,810,433 A (TAKAYANAGI et al) 07 March 1989 (07.03.1989), see whole document.	1-29, 37-72
<input type="checkbox"/> Further documents are listed in the continuation of Box C. <input type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent published on or after the international filing date "L" documents which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" documents referring to an oral disclosure, use, exhibition or other means "P" documents published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 13 May 2002 (13.05.2002)		Date of mailing of the international search report 12 JUN 2002
Name and mailing address of the ISA/US Commissioner of Patents and Trademarks Box PCT Washington, D.C. 20231 Facsimile No. (703)305-3230		Authorized officer John Niebling Telephone No. (703) 308-1782